

FT 217 : Flat Pattern Making II

Explores garment development using a personal full size sloper as a foundation for pattern making. Emphasizes application of flat pattern principles and garment construction techniques appropriate to the design. (Letter grade only.)

Credits 3

Lab Hours 45

Lecture Hours 30

Teaching Equivalent 3.13

Prerequisites

FT 113 and FT 115, both with grade C or better; or consent.

Corequisite Courses

[FT 215: Flat Pattern Making I](#)